

Inventor: Wuwen Yi et. al.

Title: Physical Vapor Deposition Targets

Assignee: Honeywell International Inc.

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10/046330  
jc872 U.S. PTO

INFORMATION DISCLOSURE STATEMENT

PURSUANT TO 37 C.F.R. §§1.56, 1.97 AND 1.98

In compliance with 37 C.F.R. §§1.56, 1.97 and 1.98, your attention is directed to the United States patents and other references listed on the attached Form PTO-1449.

The listed references were cited by, or submitted to, the Office in the parent, co-pending application of the above-identified application. The above-identified application is a Continuation-in-Part of co-pending application Serial No. 09/578,829 filed May 24, 2000. Such prior disclosure is sufficient for the above-identified application as far as copies of the references are concerned. 37 C.F.R. §1.98(d) and MPEP §609(2). No admission is made regarding whether all the submitted references are prior art.

Citation of these references is respectfully requested.

Respectfully submitted,



Dated: 10/25/2001 Attorney:

David G. Latwesen, Ph.D. Reg. #38,533  
WELLS, ST. JOHN, ROBERTS,  
GREGORY & MATKIN P.S.